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Reg. No.:....

Name :

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RIAL CSI HISTITUTE OF THE OF TH

Seventh Semester B.Tech. Degree Examination, May 2014 (2008 Scheme)

08.736 (Elective - IV): MEMS (TA)

Time: 3 Hours

Max. Marks: 100

PART-A

Answer all questions. Each question carries 4 marks.

- 1. Explain the working of chemical sensors.
- 2. List any few commonly used microsystem products.
- 3. Describe the working of a micro-valve.
- 4. Write notes on electroplating, with relevant equations.
- 5. Write notes on silicon piezo resistors.
- 6. Comment on the scaling of electric power supply while miniaturizing devices.
- 7. What are the important materials commonly used in the manufacture of MEMS systems?
- 8. Explain the features of bulk micromachining.
- 9. How will you select a particular manufacturing process for a particular microsystem fabrication?
- 10. List a few RF MEMS components and give their applications.

(10×4=40 Marks)

PART-B

Answer any two questions from each Module. Each quesion carries 10 marks.

Module - I

- 11. Explain the principle of operation of micromotors with the help of neat diagrams.
- 12. Explain the working of different types of microaccelerometers.
- 13. Describe the multidisciplinary nature of MEMS.



Module - II

- 14. Explain the various steps and materials involved in surface micromachining.
- 15. Describe:

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- a) Chemical etching and b) Plasma etching.
- 16. Compare the properties of various silicon compounds used in microsystem fabrication.

Module - III

- 17. Describe signal mapping and transduction for a micropressure sensor.
- 18. Write notes on the three levels of microsystem packaging.
- 19. Explain microsystem design considerations.

(6×10=60 Marks)